

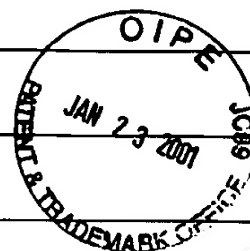
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APPLICANT
Takahiro MATSUO, et al.

FILING DATE
April 18, 2000

GROUP



U.S. PATENT DOCUMENTS

[illegible]

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JAN 25 2001
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FOREIGN PATENT DOCUMENTS

EXAMINER'S INITIALS	PATENT NO.	DATE	COUNTRY	CLASS	SUBCLASS	Translation	
						Yes	No
OK	0 691 674	1/10/96	Europe				
CH	0 515 212	11/28/92	Europe				
CH	0 519 128	12/23/92	Europe				

OTHER ART (Including Author, Title, Date, Pertinent Pages, Etc.)

9A	"Photosensitive Polymers Bearing Iminooxysulfonyl Groups. A Water Soluble Positive-Type Photoresist", by Shirai et al, Die Markomol. Chemie. Macromolecular Chemistry and Physics, Vol. 90, No. 9, pp. 2099-2107 (1989).
9A	Shirai et al, 114:63167, Chemical Abstracts, America Chemical Society, Columbus, Ohio, Abstract of J. Appl. Polym. Sci. (1990), Vol. 41, No. 9-10, pp. 2527-2532.
EXAMINER	DATE CONSIDERED
cr	01-30-01

EXAMINER: Initial if reference considered, whether or not citation is in conformance with MPEP 609; draw line through citation if not in conformance and not considered. Include copy of this form with next communication to Applicant.

All prior art is already of record.